

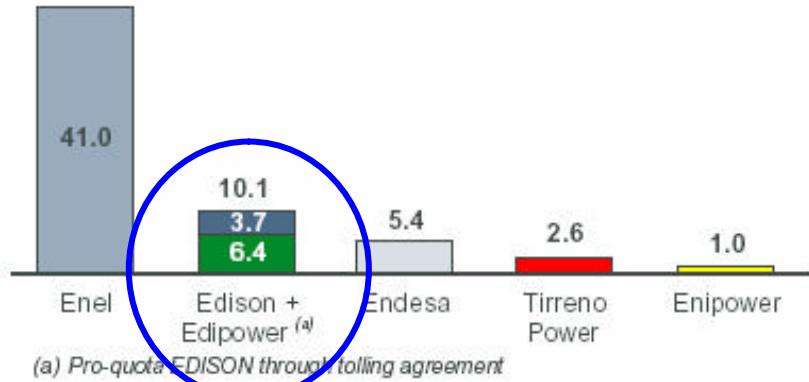
# **EDISON activities on HTS and MgB<sub>2</sub>**

S. Zannella, Edison SpA

WAMS-2004  
Workshop on Accelerator Magnet Superconductors  
Archamps, 22-24 March 2004

## Edison today - the competitive position

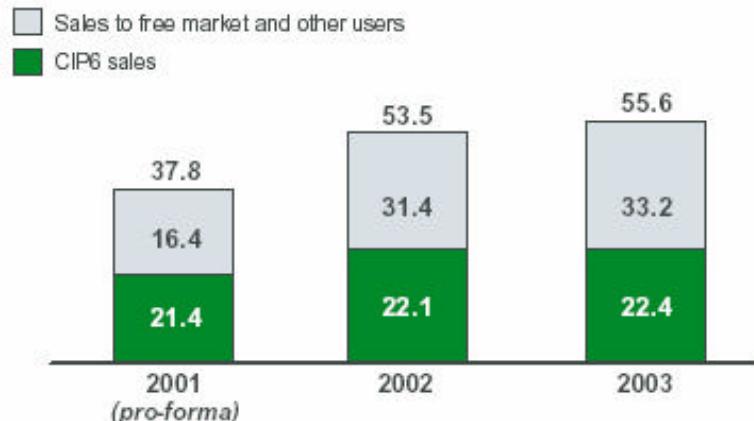
2003 Electricity Installed Capacity - Gw



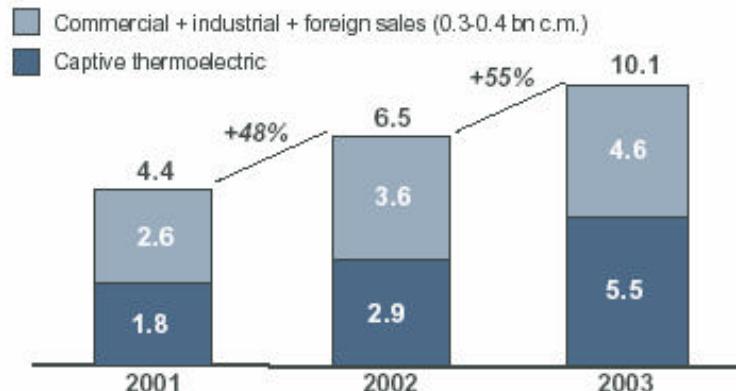
2003E Gas Supply (production and import) – bcm



Electric Power sales (TWh)



Natural Gas sales (bn c.m.)



# R&D Themes

- Hydrogen
- Fuel cells
- Sustainable energy generation
- Distributed Generation
- Power Quality
- Superconductivity

# Superconductivity

## Development of processes for innovative superconducting wires/bulks

- Y-123 coated conductors by thermal co-evaporation (partners: Europa Metalli Superconductors and CNR-I MEM)
- Bi-2212 electrodeposited tapes (CEA)
- MgB<sub>2</sub> bulks and wires (CNR-I ENI)

# Coated conductors by thermal coevaporation

**Joint team:** EDISON, Europa Metalli Superconductors,  
CNR- I MEM.

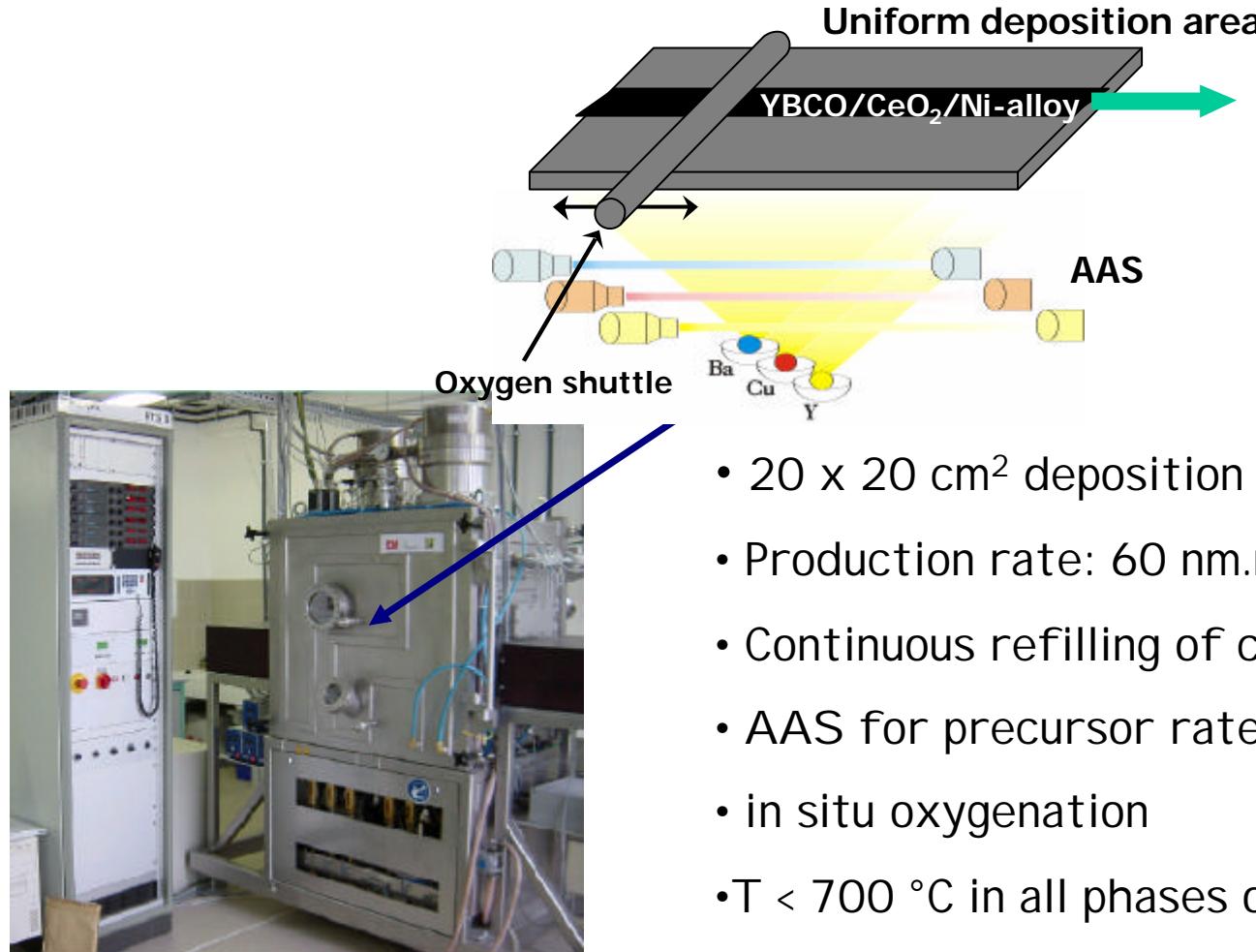
**Location:** CNR-I MEM Laboratories (Parma, Italy).



**Objective:** Development of long Y-123 coated conductors  
with  $J_c > 200 \text{ A/cm-width}$ .

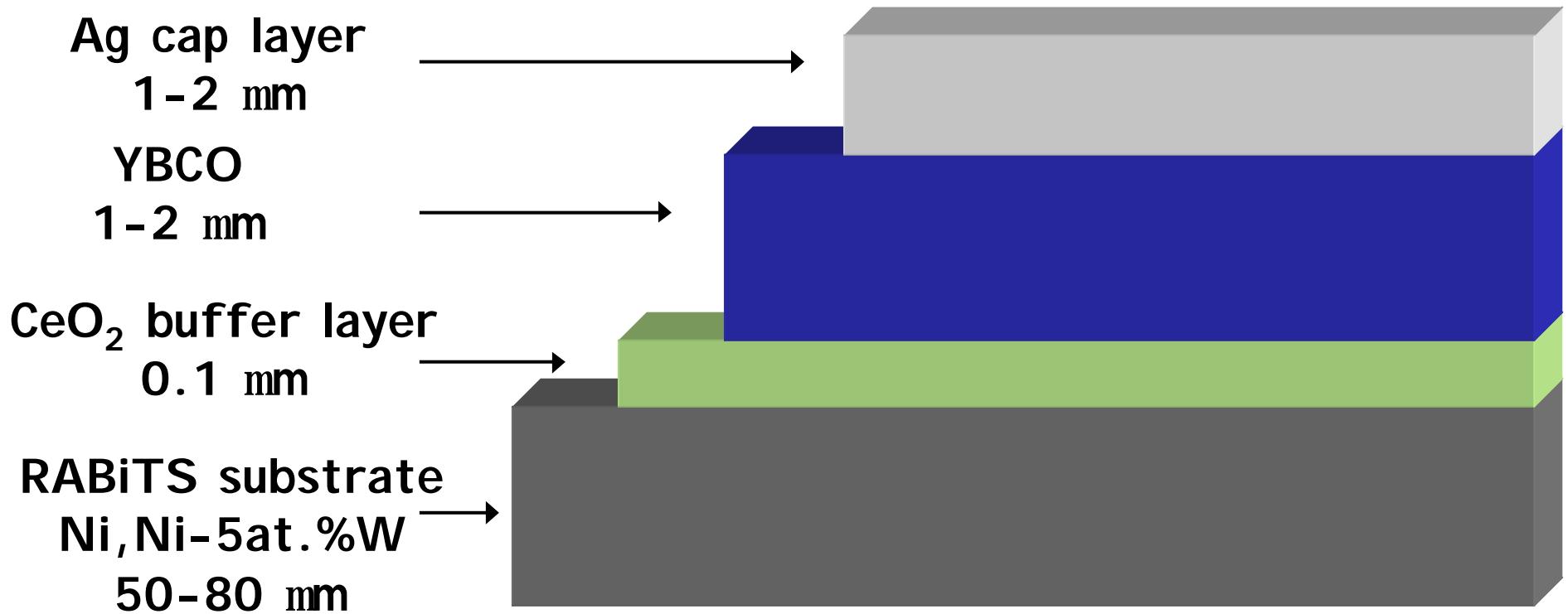
Work partially supported by CNR National Project (L. 95/95)

# Thermal co-evaporation THEVA system for continuous production of coated conductors

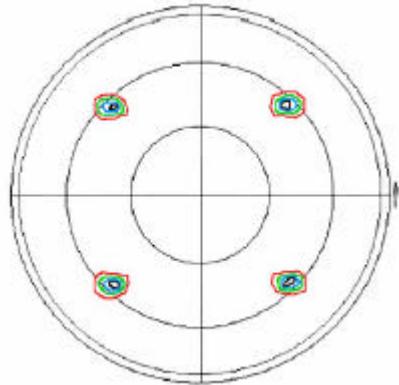


- 20 x 20 cm<sup>2</sup> deposition area
- Production rate: 60 nm.m<sup>2</sup>/h
- Continuous refilling of crucibles
- AAS for precursor rate control
- in situ oxygenation
- T < 700 °C in all phases of the process

# Multilayer architecture of Coated Conductor (CC)



# Textured tapes Ni e Ni-5 at.%W

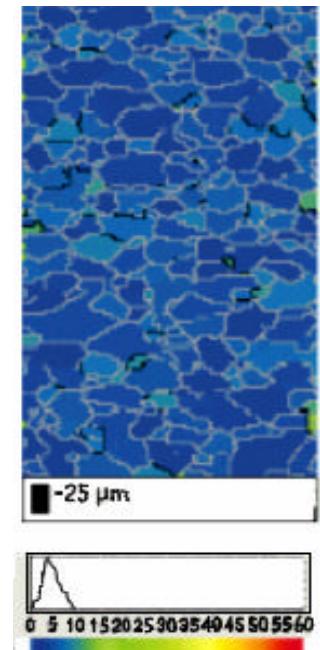
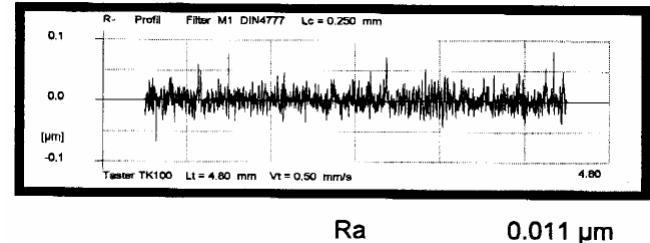


(111) Pole figure

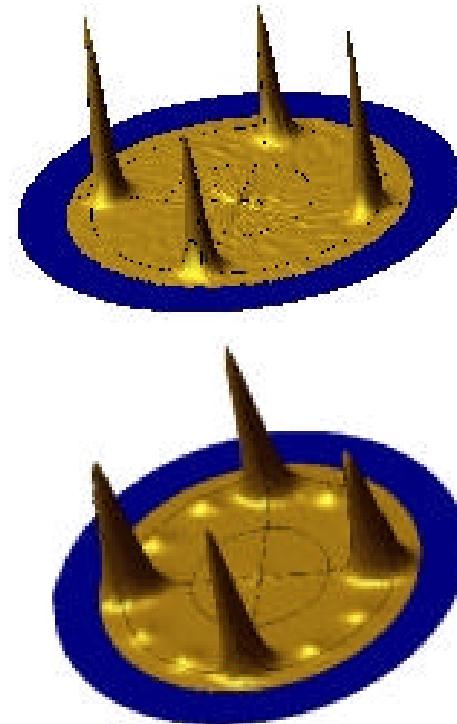
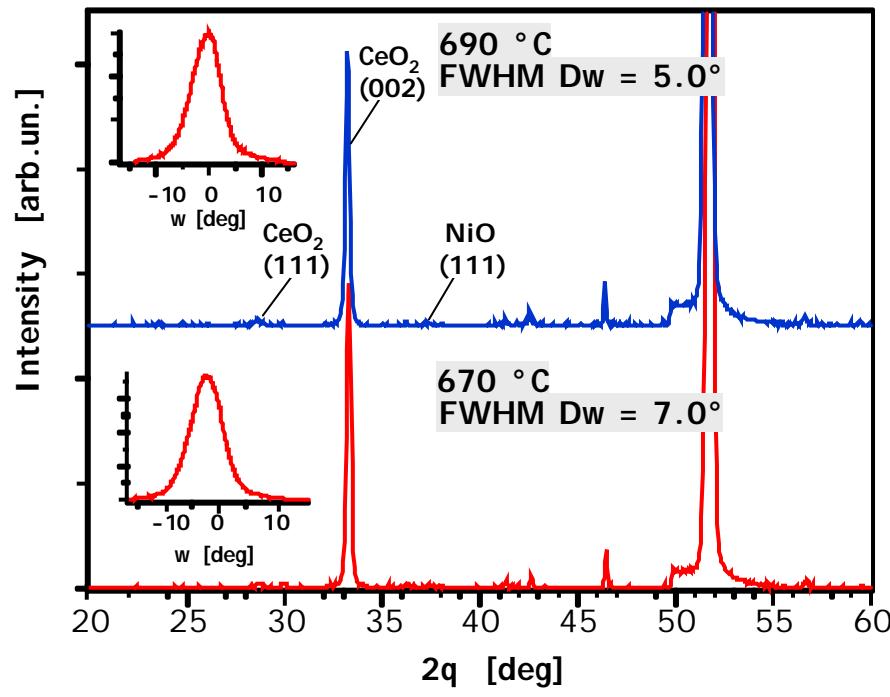
Supplier:  
thickness:  
width:  
Roughness  $R_a$ :

IFW, Dresden (Germany)  
80  $\mu\text{m}$   
1 cm  
 $< 15 \text{ nm}$

	<i>In-plane</i>	<i>Out-of-plane</i>
	$\Delta\phi$	$\Delta\chi$
NiW	7.7°	7.7°



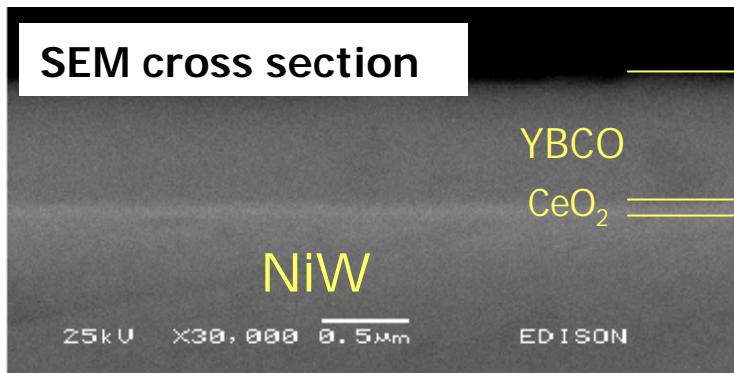
# CeO<sub>2</sub> Buffer Layer



CeO<sub>2</sub> layer texture data

Substrate	$\Delta\phi$ <i>in-plane</i>	$\Delta\chi$ <i>out-of-plane</i>
Ni	5.8°	5.0°
Ni 5at.%W	6.0°	4.8°

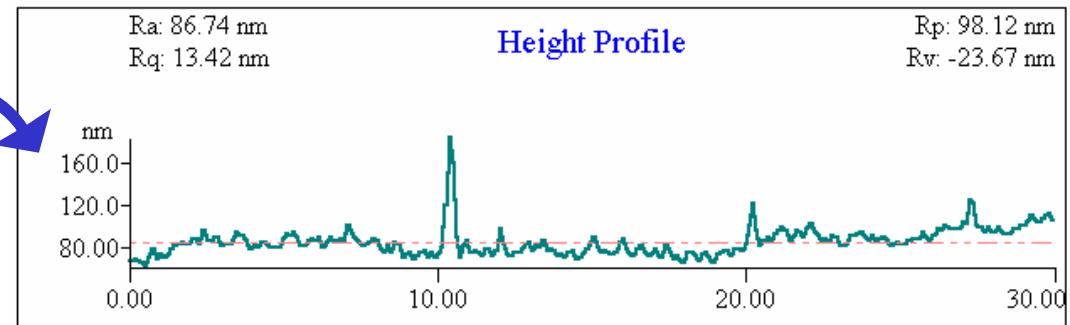
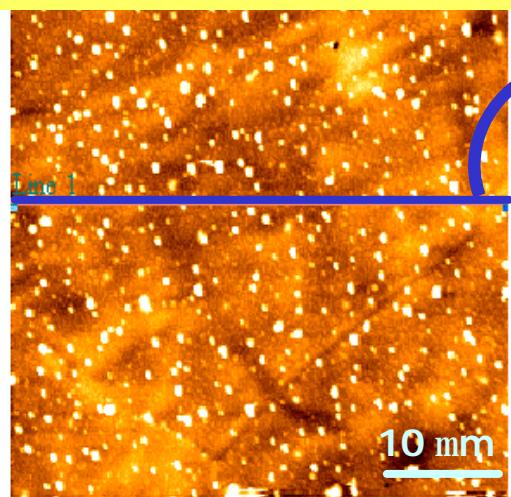
# CeO<sub>2</sub> Buffer layer



- Uniform 100 nm thick CeO<sub>2</sub> layer;
- crack free surface
- Sharp interfaces.



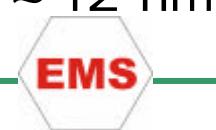
AFM topography



average roughness:

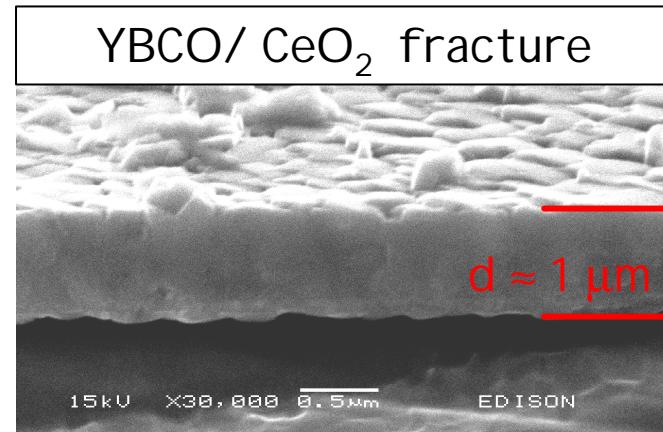
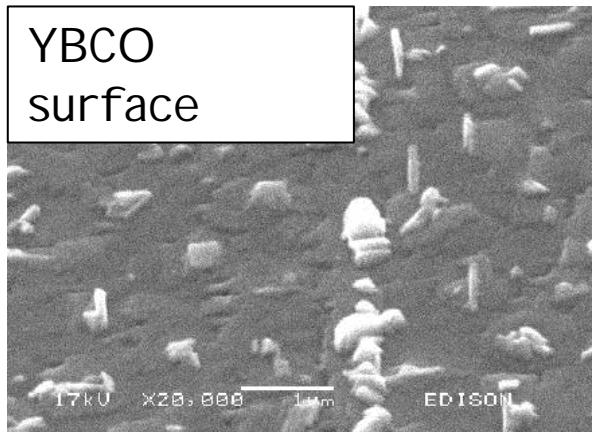
$$R_{av}(\text{CeO}_2) \approx 15 \text{ nm}$$

$$R_{av}(\text{NiW}) \approx 12 \text{ nm}$$

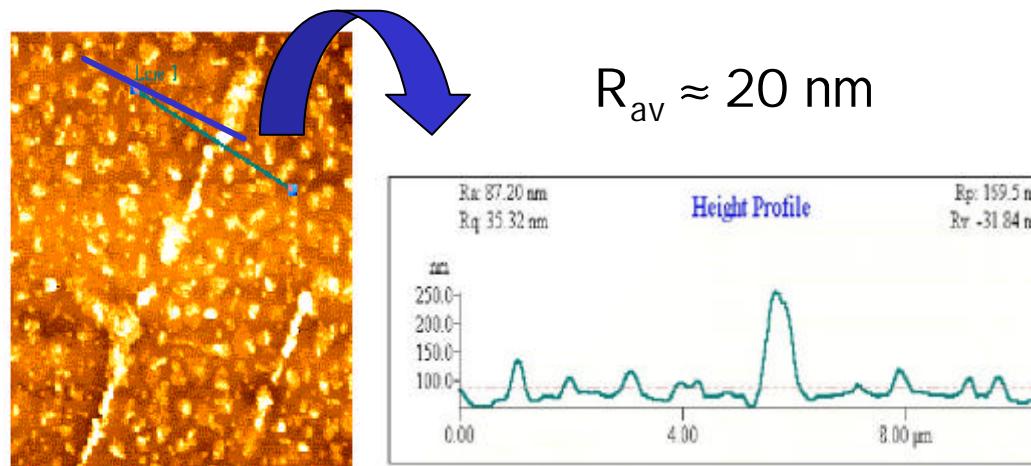


e EDISON

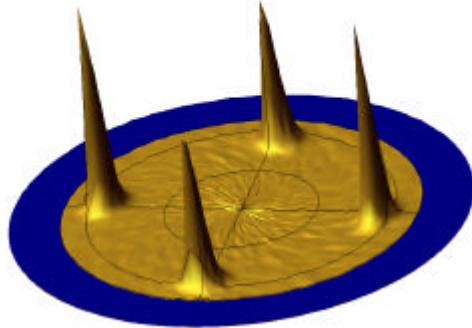
# YBCO layer



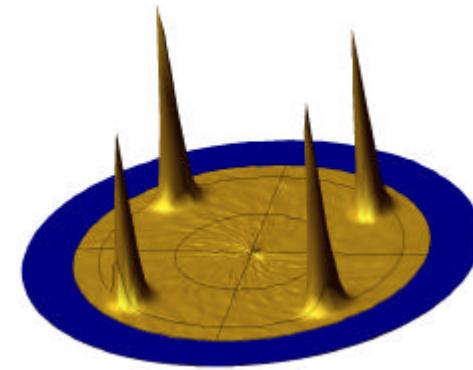
Dense YBCO layer and smooth surface



# Y-123 texture



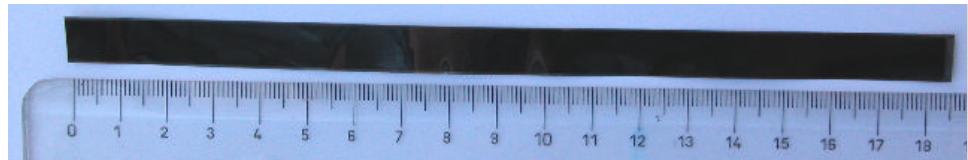
(111) CeO<sub>2</sub> pole figure



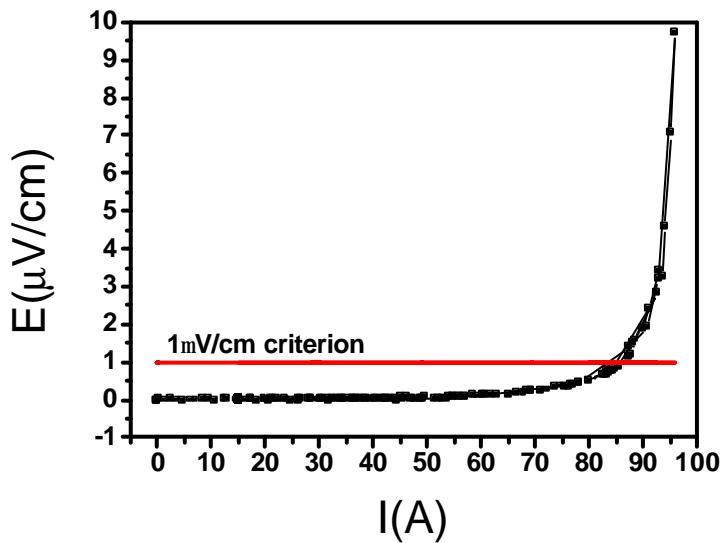
(113) YBCO pole figure

	<b>FWHM Dc</b> <i>out-of-plane</i>	<b>FWHM Dj</b> <i>in-plane</i>
<b>NiW</b>	8°	8°
<b>CeO<sub>2</sub></b>	4.8°	6°
<b>YBCO</b>	5.8°	6°

# 20 cm long Y-123 CC: transport properties



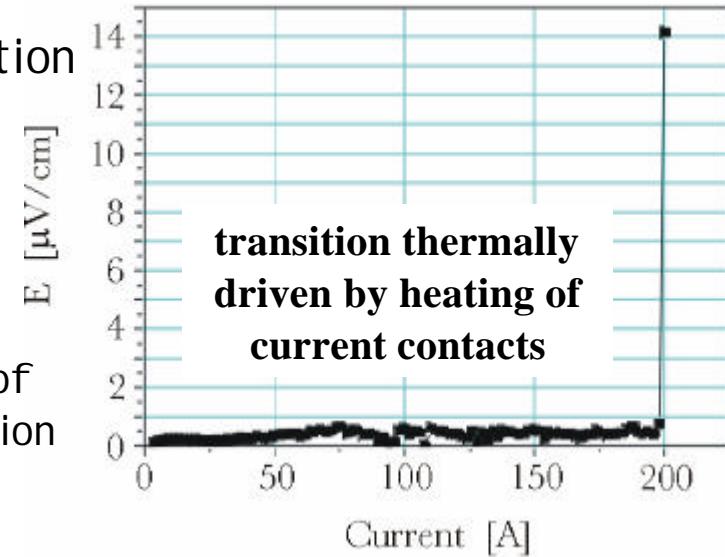
film width = 0.9 cm  
YBCO thickness = 0.85  $\mu\text{m}$



Static deposition



Optimisation of  
YBCO composition



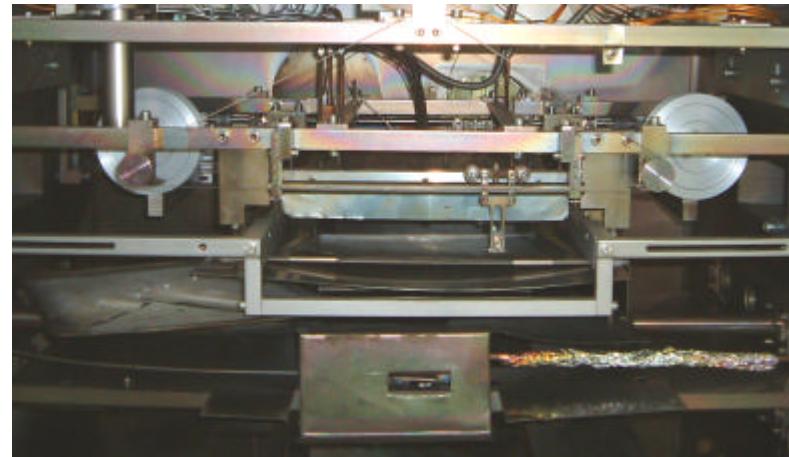
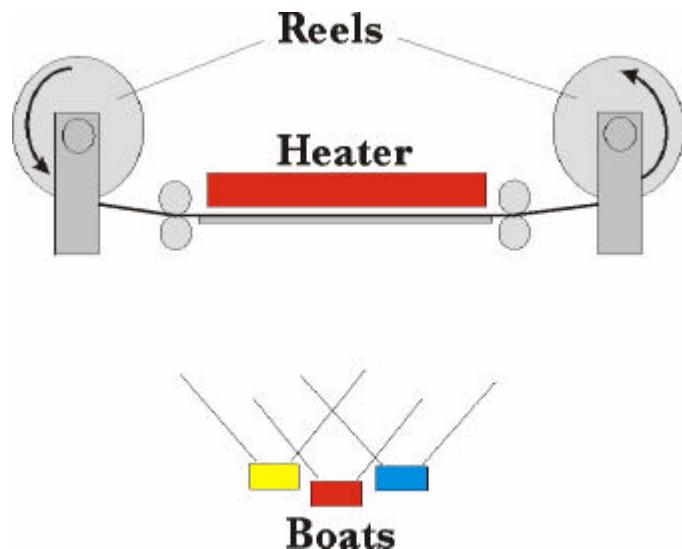
$$I_c/w = 94 \text{ A/cm-width}$$

$$J_c = 1.1 \text{ MA/cm}^2 @ 77 \text{ K, s.f.}$$

$$I_c/w = 220 \text{ A/cm-width}$$

$$J_c = 2.6 \text{ MA/cm}^2 @ 77 \text{ K, s.f.}$$

# Continuous deposition of Y-123 CC's



- Simple single-pass reel-to-reel system
- Tape speed: 0.2 - 0.4 m/h.

20 cm long CC:  $J_C=1.8 \text{ MA/cm}^2$

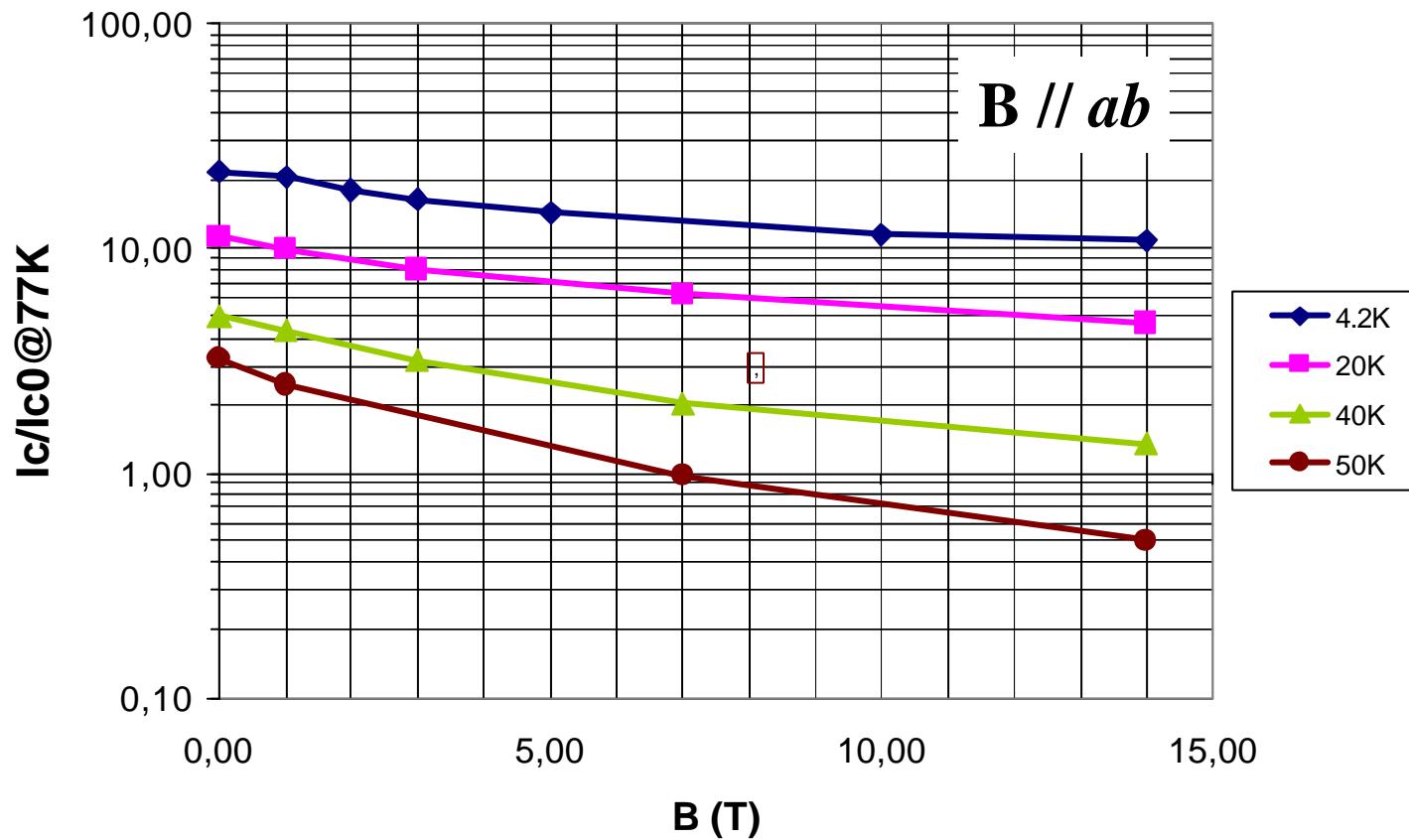
# Continuous deposition of CC's



1 meter long CC:  $J_c=1-2 \text{ MA/cm}^2$

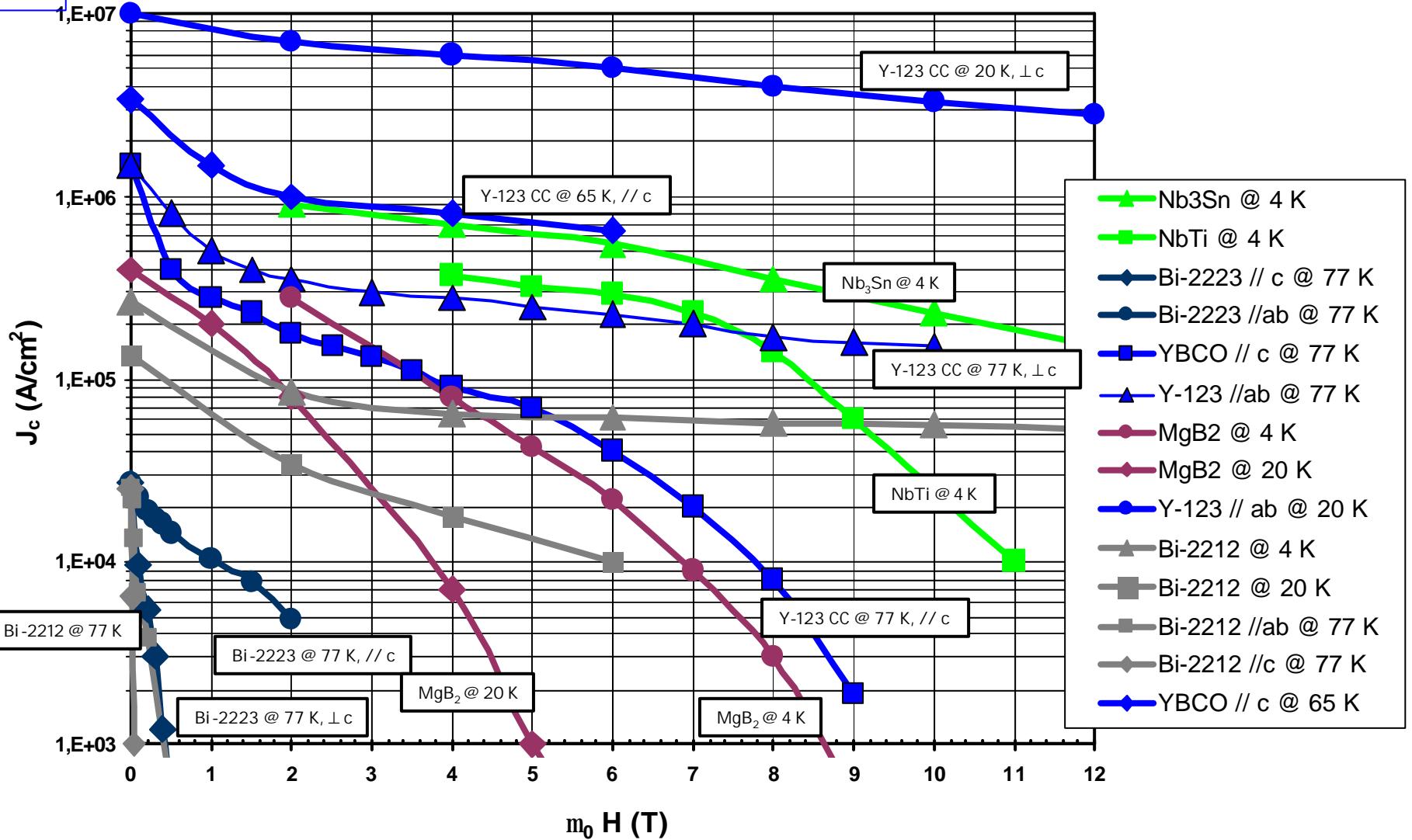
Next goal: 3 m long CC with  $I_c > 200 \text{ A/cm-width}$  by 2004.

# $J_c$ vs B at low temperature



D. Uglietti, Département de Physique de la Matière Condensée, Université de Genève

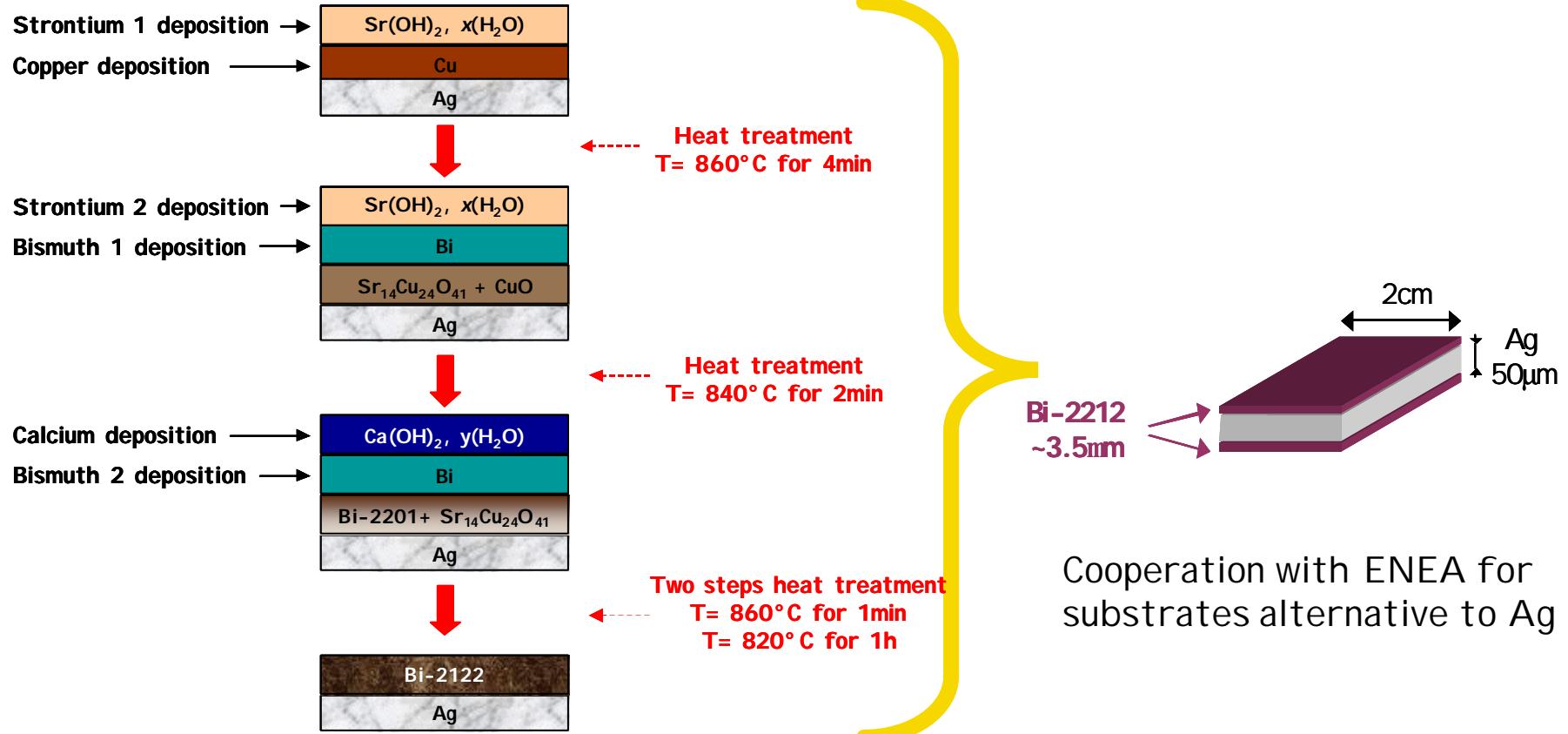
# $J_c$ (B)



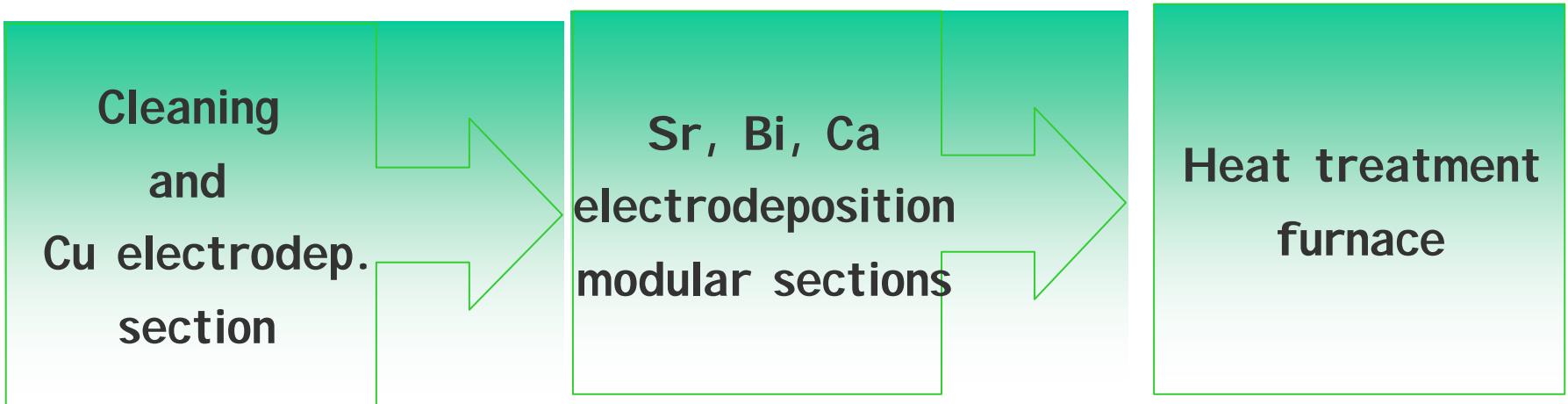
# Bi-2212 electrodeposited tapes

- No-vacuum, fast and low-cost technique.
- Silver substrate without buffer layer
- Goal: scale-up of the electrochemical process, optimized on short samples, to a pilot plant for production of long Bi-2212 long tapes by a continuous electrochemical process
- Suitable also for Y-123 deposition  
( $J_c=10 \text{ kA/cm}^2$  @ 77 K on untextured Ag substrates)

# Sequential electrodepositions



# Block diagram of pilot plant

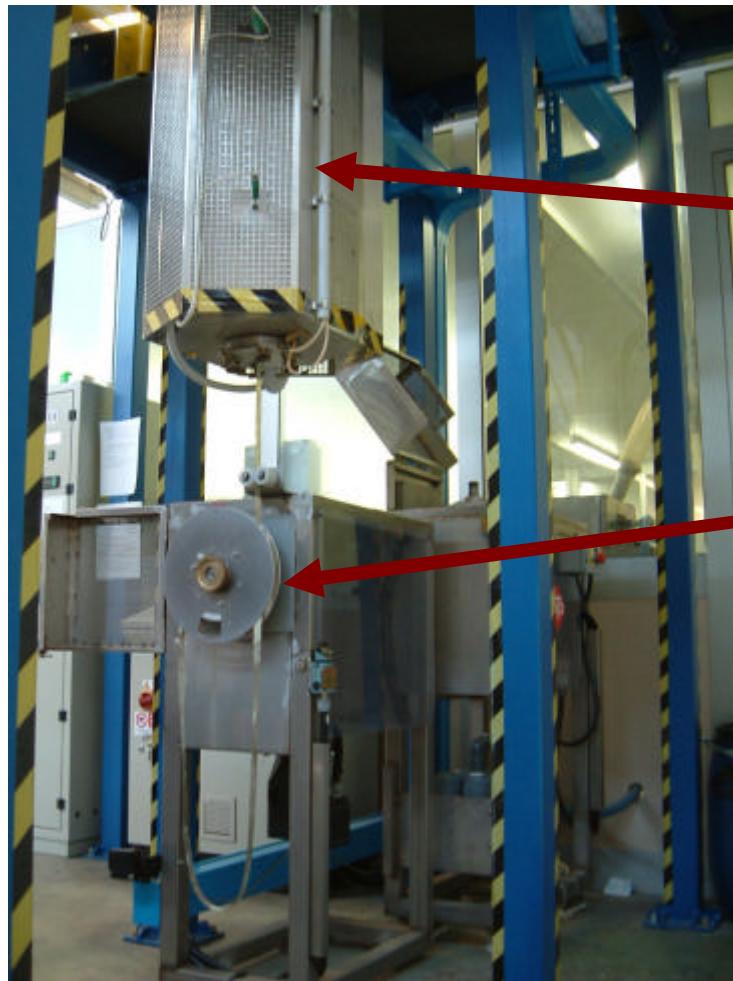


# Pilot plant

## Modular Electrodeposition Section



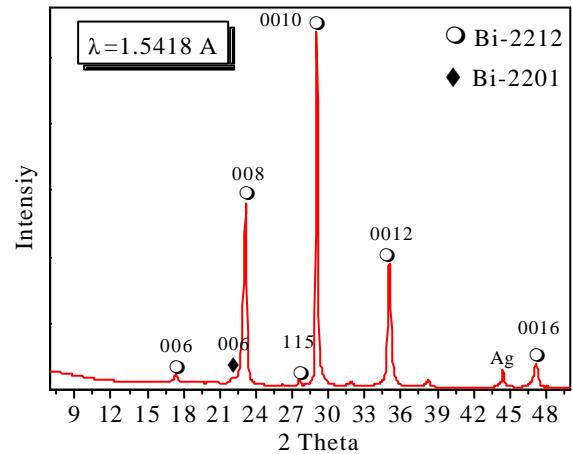
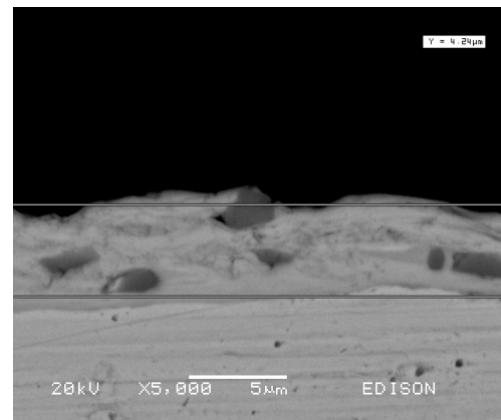
# Heat treatments furnace



Vertical tubular  
furnace

Unwinding reel

# Electrodeposited Bi-2212 tapes



Best quality Lab sample

pilot plant tape

lower density  
small size secondary phases

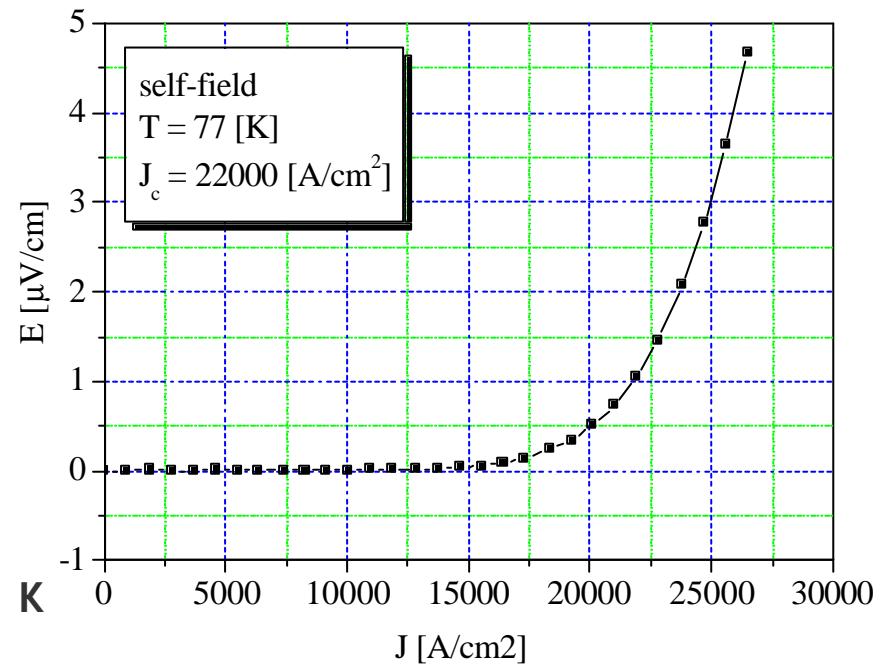
# Electrical performances



$J_c$  transport measurement



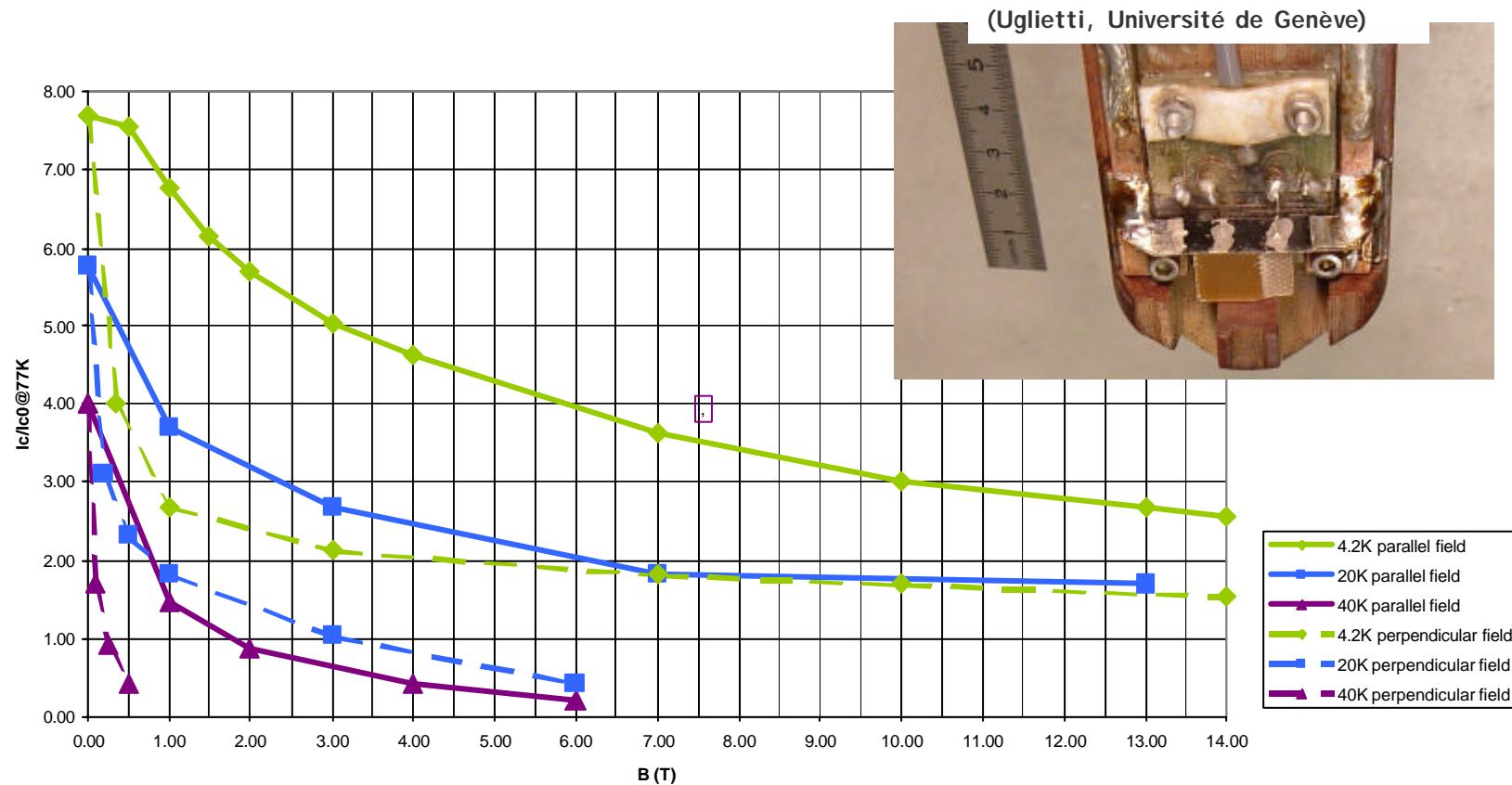
20x2 cm long sample  $J_c > 25 \text{ kA/cm}^2$  @ 77 K



100x2 cm long sample  $J_c > 15 \text{ kA/cm}^2$  @ 77 K cut from 20 m of electrodeposited tape

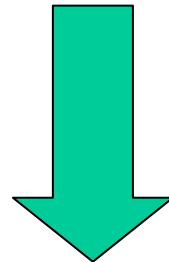
Next goal: 10 m, 20 kA/cm<sup>2</sup> by 2004 (end of funded national project)

# Critical current vs magnetic field



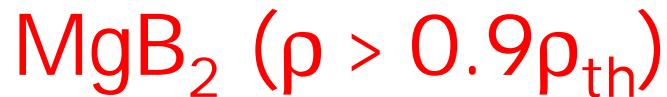
# High density MgB<sub>2</sub> by Reactive Liquid Infiltration (RLI)

“in situ” process by the following reaction:



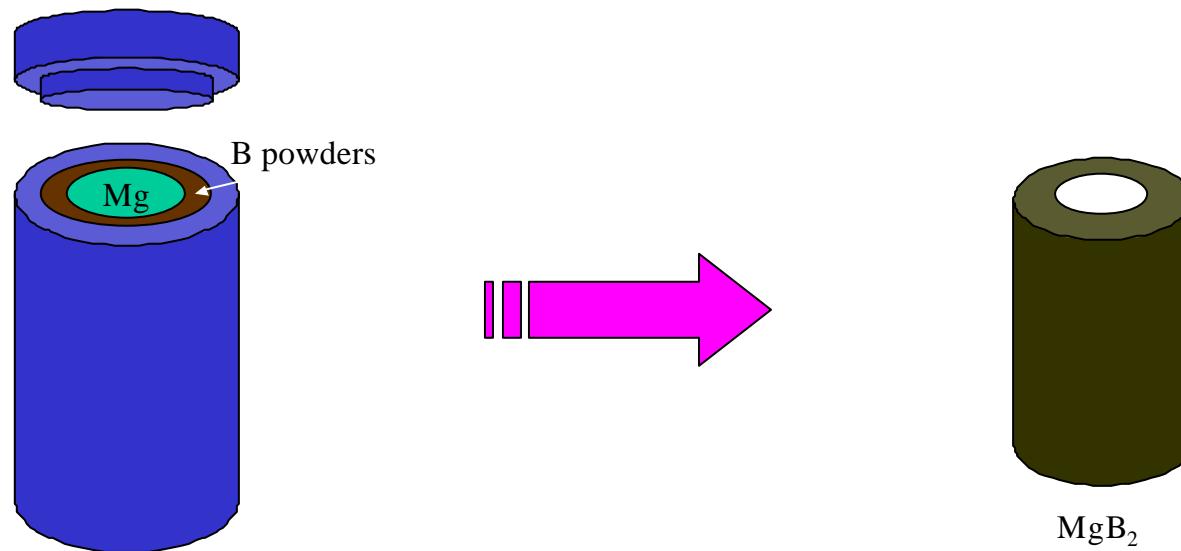
Temperature (750 °C – 1000 °C)

Pressure (> 1 atm)

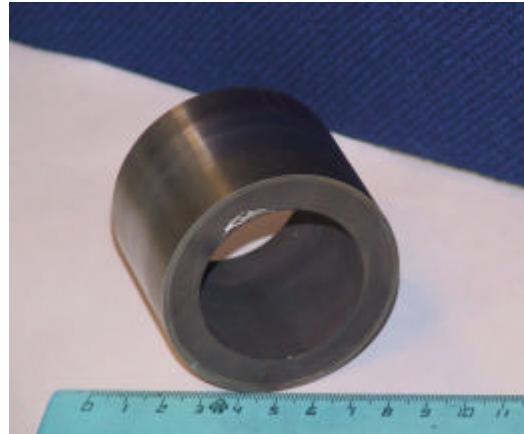


# Bulk MgB<sub>2</sub> manufacturing

The reaction is performed in a sealed stainless steel container and the final shape resembles the shape of the B preform.



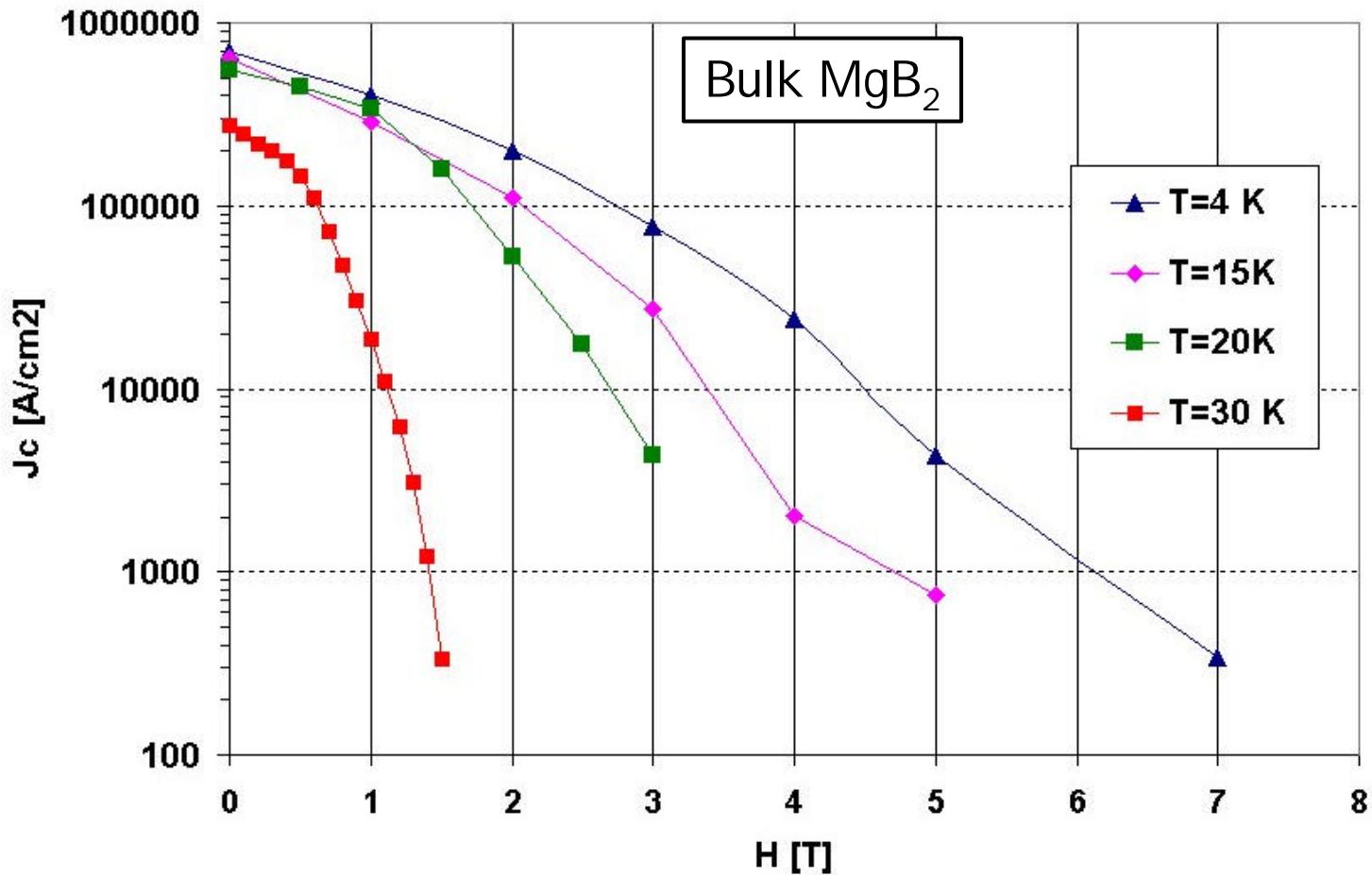
# Bulk MgB<sub>2</sub> Manufact



# Benefits of the RLI technology

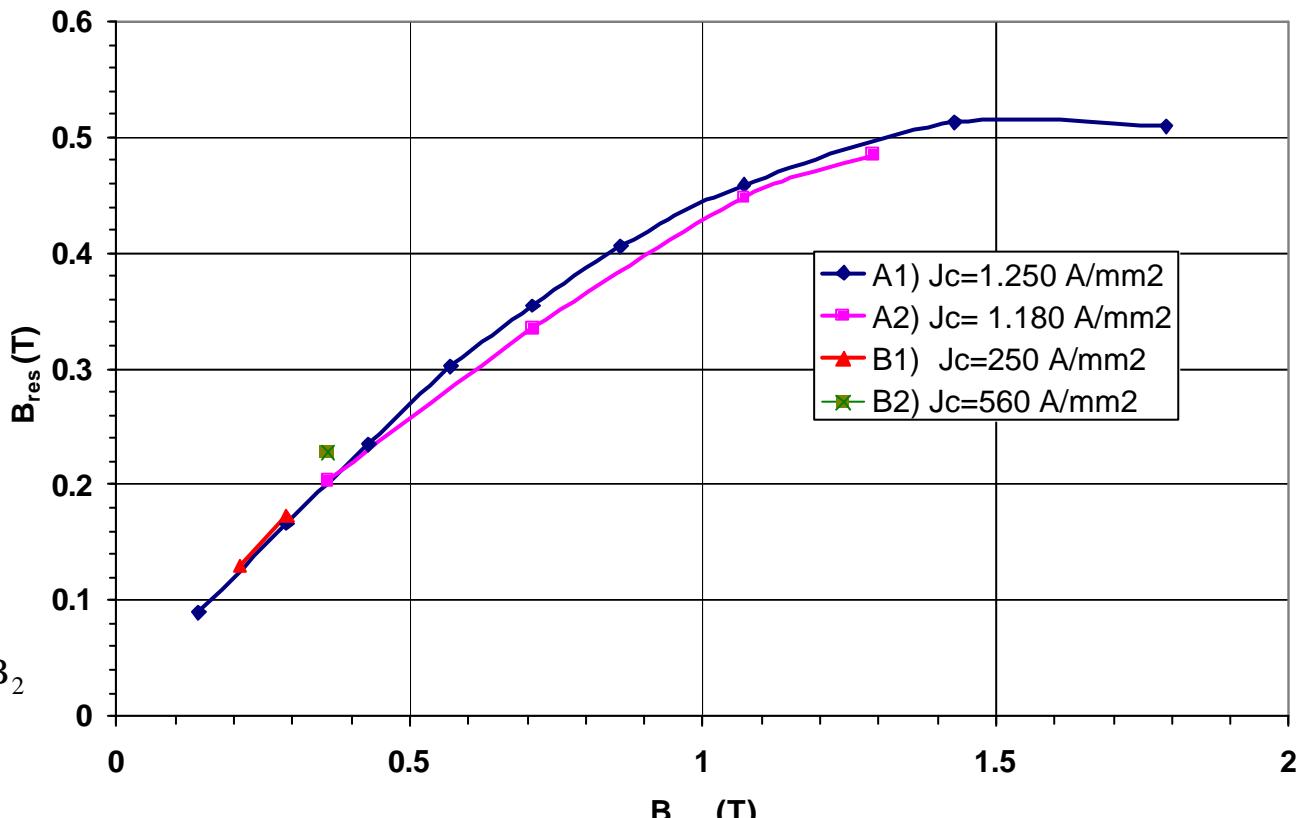
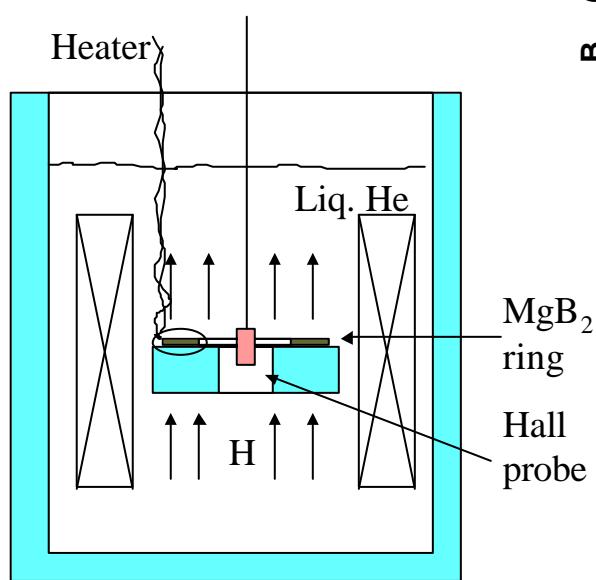
- High density products with a low pressure process.
- Large and thick sample manufacturing.
- Valid for bulk and wires.

# Magnetic critical current density



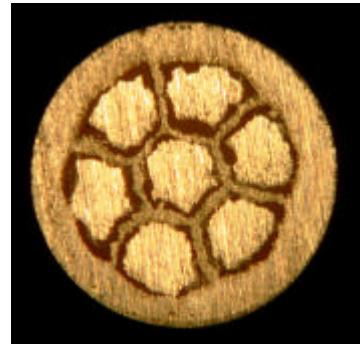
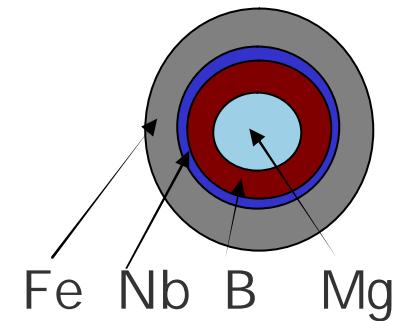
# Trapped Magnetic Field

MgB<sub>2</sub> hollow disk , 1 mm thick ( $\phi_{\text{int}}/\phi_{\text{ext}}=25/46 \text{ mm}$ )

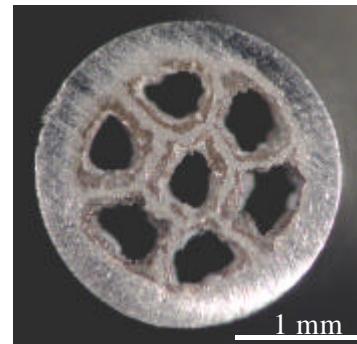


# Hollow wire manufacturing

- Cold working of a composite billet ,
- Assembling many billets for multiwire manufacturing
- Clamping the terminals
- Thermal treatment



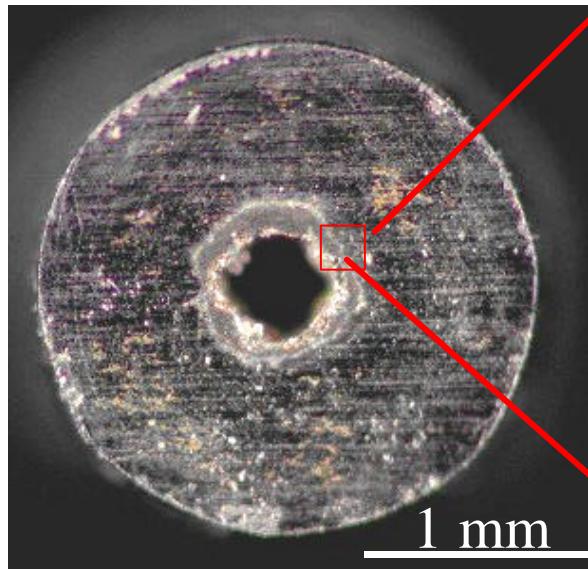
a)



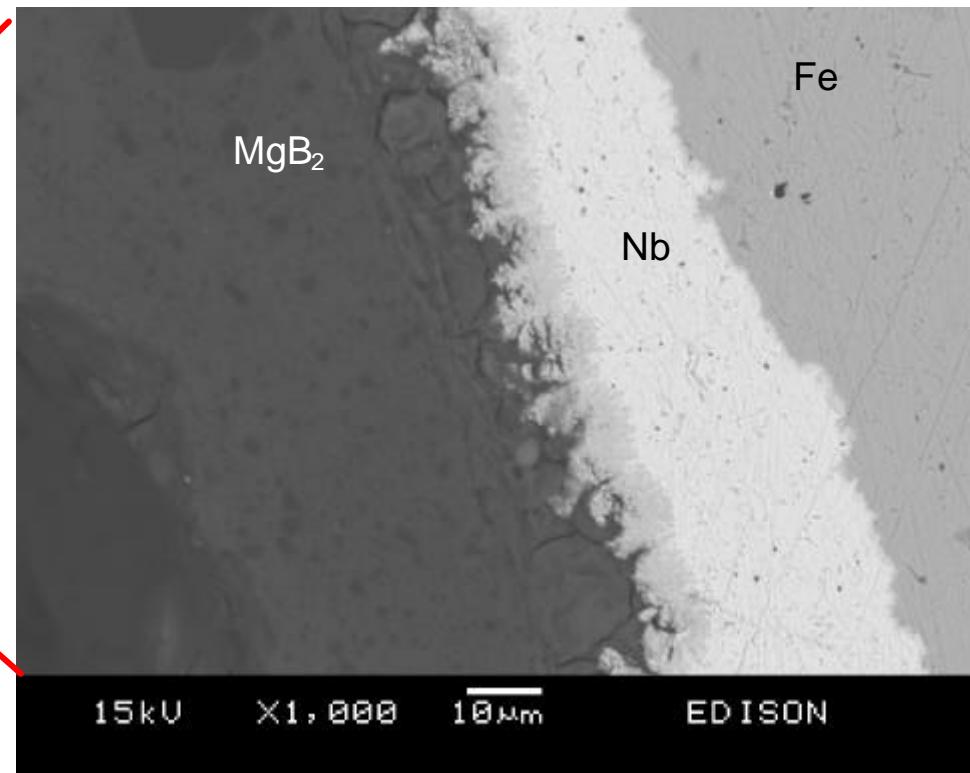
b)

Optical microographies of the cross sections of a 7-filament multiwire:  
a) precursor wire, b) annealed superconducting wire

# MgB<sub>2</sub> Monofilamentary wire



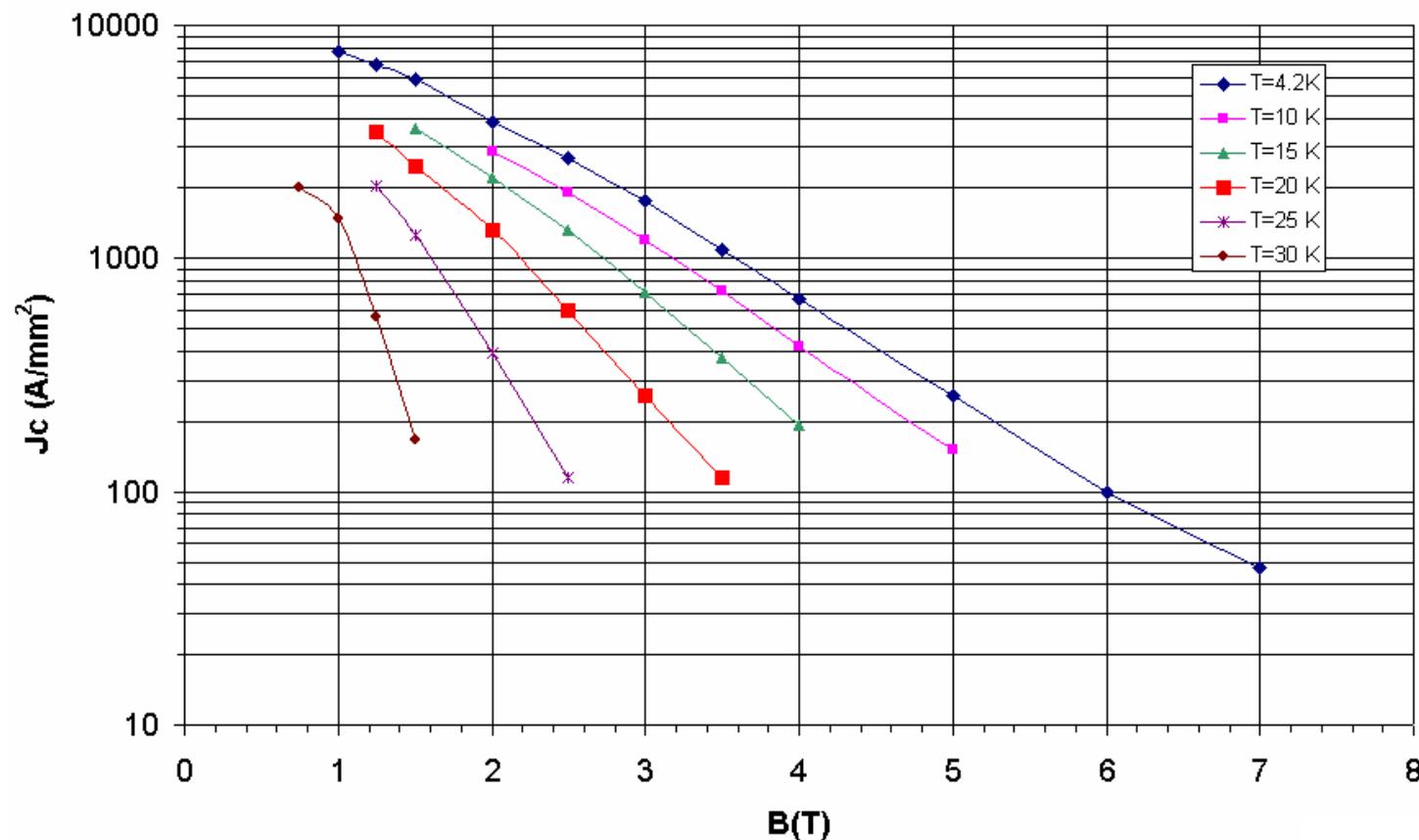
Optical cross section  
cross section



Backscattered electrons

# $J_c$ (B) of $MgB_2$ monofilamentary wire

( $A_{SC} = 0.1 \text{ mm}^2$ ,  $A_{tot} = 1.23 \text{ mm}^2$ )



Bruzzone, EPFL-CRPP, Villigen

WAMS-2004, Archamps, 22-24 March 2004

# n-factor

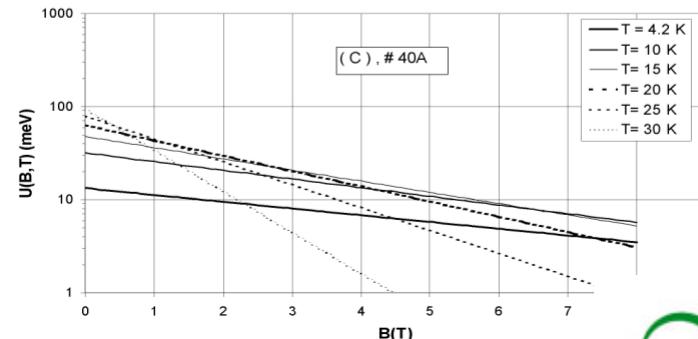
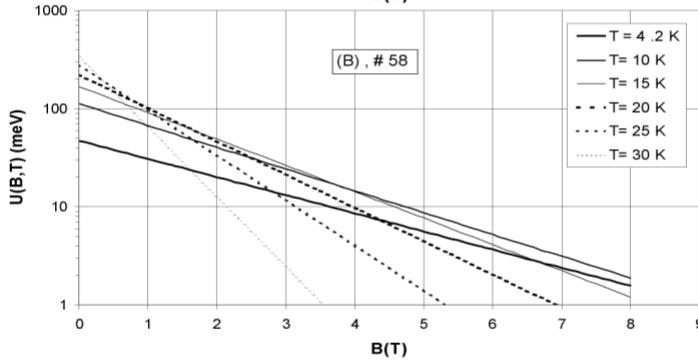
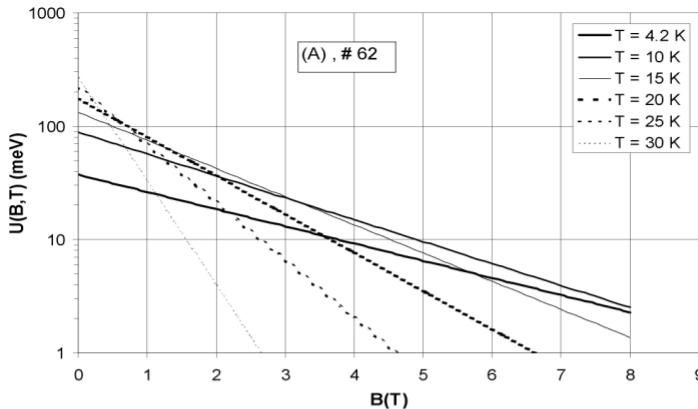
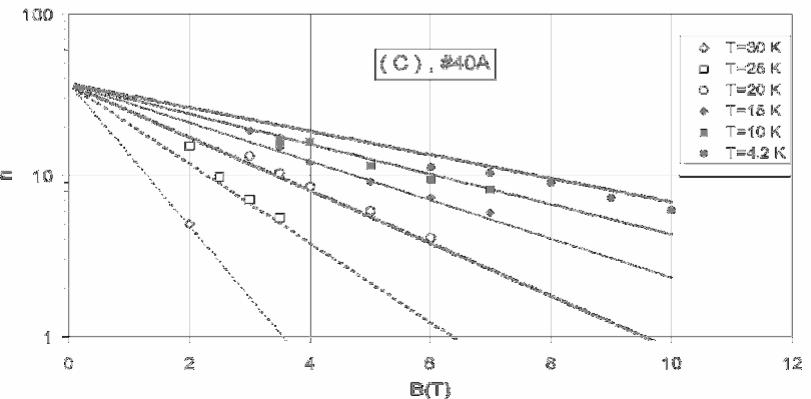
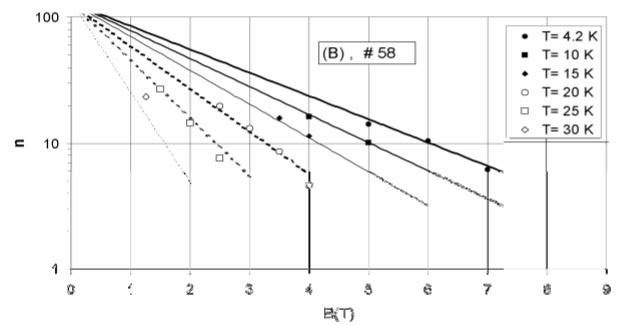
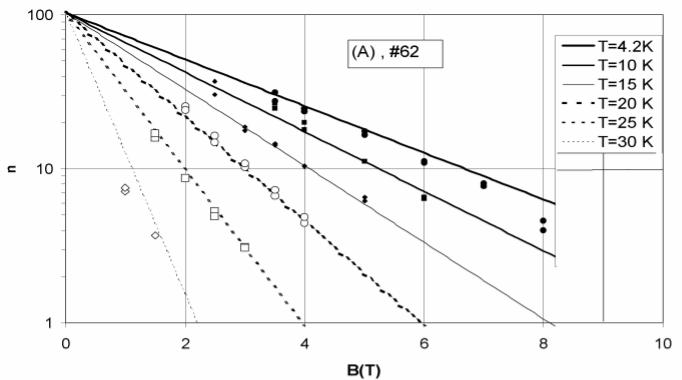
The n-factor for different specimens are interpolated according to the following relation:

$$n(B, T) = n_0 \exp(-aB/(1 - T/T_c)^b)$$

parameters  $n_0$ ,  $\alpha$ ,  $\beta$  determined by fit of the exp. values

MgB <sub>2</sub> Samples	n <sub>0</sub>	a (1/T)	b
(A) - Bulk (#62)	103	0.30	1.33
(B) -Monofilament wire (#58)	130	0.38	1.00
(C ) -7-filaments wire (#40A)	37	0.145	1.33

# n-factor and flux flow activation energy



# MgB<sub>2</sub>

- MgB<sub>2</sub> is potentially interesting for applications at intermediate magnetic fields and intermediate temperatures (< 20 K).
- The high potentiality of MgB<sub>2</sub> to reach rapidly a wide market is related to the low prospective costs of raw materials and of the manufacturing process.